

CONTENTS

<i>List of Figures</i>	x-xiv
<i>List of Tables</i>	xv
<i>List of Abbreviations</i>	xvi-xviii
<i>List of Symbols</i>	xix-xxi
<i>Preface</i>	xxii-xxvi
CHAPTER 1	1-46
Introduction and Scope of the Thesis	
1.1 Solar Cell	3
1.1.1 Origin of Solar Cells	4
1.1.2 Generation of Solar Cells	5
1.2 Perovskite Solar Cell	8
1.2.1 Perovskite Material	9
1.2.1.1 Crystal Structure	10
1.2.1.2 Optoelectronic Properties	11
1.2.2 Working Principle of Perovskite Solar Cells	13
1.2.3 Numerical Modeling of Perovskite Solar Cells	17
1.3 Fabrication Process for Perovskite Solar Cells	21
1.3.1 Electrodes	22
1.3.2 Photoabsorber Layers	23
1.3.2.1 One Step Deposition via Spin Coating	24
1.3.2.2 Two Step Deposition via Spin Coating	25
1.3.2.3 Vapor Assisted Deposition Technique	26
1.3.3 Charge Transport Layers	26
1.4 Characterization Techniques for Perovskite Solar Cells	29

1.4.1	Surface Characterization	29
1.4.1.1	Atomic Force Microscopy	29
1.4.1.2	Scanning Electron Microscopy	30
1.4.1.3	Transmission Electron Microscopy	30
1.4.1.4	X-Ray Diffraction	31
1.4.2	Optical Characterizations	32
1.4.2.1	Absorbance	32
1.4.2.2	Photoluminescence	32
1.4.3	Optoelectronic Characterizations	33
1.5	Literature Review	35
1.5.1	Review of Perovskite Based Solar Cells	35
1.5.2	Review of TiO ₂ Nanorods Based Perovskite Solar Cells	38
1.5.3	Review of ZnO Nanorod Based Perovskite Solar Cells	39
1.5.4	Major Observation from the Literature Survey	41
1.6	Issues and Challenges in Perovskite Solar Cells	42
1.7	Motivation and Problem Definition	43
1.8	Scope of the Thesis	44
CHAPTER 2		47-63
Effect of TiO₂ Nanorods (TNRs) ETL Thickness on the Performance of FTO/TNRs/CH₃NH₃PbI₃/PTAA/Pd Structure Based Perovskite Solar Cells		
2.1	Introduction	48
2.2	Experimental Details	50
2.2.1	Material Used	50
2.2.2	TiO ₂ Nanorods Synthesis and TiCl ₄ treatment	50
2.2.3	CH ₃ NH ₃ I Perovskite Precursor Synthesis	51
2.2.4	Device Fabrication	51

2.3	Numerical Modeling and Device Simulation	52
2.4	Results and Discussion	56
	2.4.1 Thin Film Characterization	56
	2.4.2 Solar Cell Characterization	58
2.5	Conclusion	62
CHAPTER 3		64-84
Effects of Solvothermal Etching and TiCl₄ Treatment of TiO₂ Nanorods (TNRs) ETL on the Performance Characteristics of FTO/TNRs/CH₃NH₃PbI₃/Spiro-OMeTAD/Pd Solar Cells		
3.1	Introduction	65
3.2	Experimental Details	66
	3.2.1 Preparation of Electron Transport Layer (ETL)	66
	3.2.2 Solar Cell Fabrication	69
	3.2.3 Material and Device Characterization	70
3.3	Results and Discussion	72
	3.3.1 Thin Film Characterization	73
	3.3.2 Solar Cell Characterization	79
3.4	Conclusion	83
CHAPTER 4		85-102
Fabrication and Characterization of FTO/ZnO Seed Layer/ZnO Nanorods/CH₃NH₃PbI₃/PTAA/Au Solar Cells with Different Seed Layers		
4.1	Introduction	86
4.2	Experimental Details	87
	4.2.1 Solution Preparation for Seed Layer	87
	4.2.2 Growth of ZnO Nanorods	89

4.2.3	Solar Cell Fabrication	91
4.3	Results and Discussion	92
4.3.1	Thin Film Surface Characteristic	93
4.3.2	Optical Characterization	95
4.3.3	Electrical Characterization	98
4.4	Conclusion	102
CHAPTER 5		103-119
Effect of Doped Spiro-OMeTAD Based HTL on the Performance of FTO/ZnO Nanorods/CH₃NH₃PbI₃/ Spiro-OMeTAD/Pd Perovskite Solar Cells		
5.1	Introduction	104
5.2	Experimental Details	105
5.2.1	Thin Film Growth and Perovskite Solar Cell Fabrication	105
5.2.2	Film and Device Characterization	107
5.3	TCAD Simulation and Models	108
5.4	Results and Discussion	110
5.4.1	Thin Film Characterization	111
5.4.2	Solar Cell Characterization	114
5.5	Conclusion	119
CHAPTER 6		120-127
Conclusion and Future Scope		
6.1	Introduction	121
6.2	Chapter-Wise Major Observations	122
6.3	Future Scope of Work	126
<i>References</i>		128-147
<i>Author's Relevant Publications</i>		148-149

LIST OF FIGURES

Figure 1.1:	Various non-renewable and renewable energy sources.	4
Figure 1.2:	Different generations of solar cells.	7
Figure 1.3:	Comparative rapid growth in PCE for perovskite based solar cells.	8
Figure 1.4:	(a) Structure of ABX_3 perovskite (b) Cubic unit cell of $CH_3NH_3PbI_3$.	11
Figure 1.5:	Band structure of $MAPbI_3$.	12
Figure 1.6:	General structure of perovskite solar cell.	14
Figure 1.7:	Electrical equivalent model of the perovskite solar cell.	15
Figure 1.8:	J-V curve for PSC device where the red curve is for under illumination and black is for dark. The area in the shade gives maximum achievable power.	16
Figure 1.9:	Band-to-band, SRH, and Auger recombination.	21
Figure 1.10:	Block diagram of physical vapor deposition.	22
Figure 1.11:	Deposition methods for the perovskite thin film (a) Physical vapor deposition, (b) One step deposition, and (c) Two step deposition.	24
Figure 1.12:	Measurement setup for (a) AFM, (b) HRSEM, (c) TEM, and	31

	(d) XRD.	
Figure 1.13:	Measurement setup for (a) Photoluminescence spectrometer and (b) UV-Vis absorption spectroscopy.	33
Figure 1.14:	Optoelectronic characterization setup for perovskite solar cells.	34
Figure 1.15:	Progress in power conversion efficiency of PSCs from 2005 to 2018.	36
Figure 2.1:	(a) Device structure of the PSCs. (b) Band diagram for the fabricated PSCs structure under equilibrium.	52
Figure 2.2:	(a) Equivalent circuit of perovskite solar cell; (b) Equivalent J - V characteristic and performance parameters of PSC.	52
Figure 2.3:	(a) HRSEM image of TNRs and (b) EDS image of TNRs.	57
Figure 2.4:	(a) XRD pattern of hydrothermally synthesized TNRs and (b) PL emission spectra of perovskite thin film.	57
Figure 2.5:	HRSEM image of (a) perovskite thin film surface (b) Cross-sectional view of PSC structure without metal electrode.	58
Figure 2.6:	(a) Absorbance spectra of hydrothermally synthesized and simulated TNRs on FTO coated glass substrate, (b) Absorbance spectra of synthesized and simulated perovskite thin film.	58
Figure 2.7:	J - V curve of fabricated and simulated PSCs with (a) 500 nm TNRs, (b) 650 nm TNRs, (c) 800 nm TNR	60
Figure 2.8:	External quantum efficiency of fabricated and simulated PSCs with 500 nm ETL, 350 nm active layer and 100 nm HTL.	62
Figure 3.1:	(a) FTO coated glass, (b) TiO_2 seed layer on FTO coated glass, (c) Hydrothermal Process at 170°C in Teflon lined cylinder, (d) TNRs after hydrothermal process, (e) Solvothermal etching of	68

	TNRs at 180 ⁰ C and (f) TiO ₂ NRs after solvothermal etching.	
Figure 3.2:	Fabrication steps used for device A, B and C.	71
Figure 3.3:	(a) The device structure of PSC after solvothermal etching of TiO ₂ NRs and (b) Schematic representation of the energy band diagram of PSC.	72
Figure 3.4:	(a) XRD analysis of TiO ₂ NRs annealed at 450 ⁰ C. (b) Energy dispersive spectroscopy (EDS) and elemental composition of TNRs.	74
Figure 3.5:	(a) And (c) are the TEM images of pristine rutile TNRs and TNRs after solvothermal etching respectively. Fig. (b) and (d) are the selected area electron diffraction patterns corresponds to Fig (a) and (b) respectively.	75
Figure 3.6:	Top view SEM image of TNRs annealed at 450 ⁰ C in ambient environment before solvothermal etching: (a) 200 nm scale, (b) 500 nm scale (Inset of Figure 3.6 (b) shows the cross-sectional image of TNRs at 500 nm scale); after solvothermal etching: (c) 200 nm scale, (d) 500 nm scale. Top SEM image of perovskite thin film deposited on solvothermal etched TNRs (e) 200 nm scale and (f) 500 nm scale.	76
Figure 3.7:	AFM image of TNRs without solvothermal etching (a) 2D and (b) 3D. AFM image of TNRs with solvothermal etching (c) 2D and (d) 3D. AFM image of perovskite film deposited on etched TNRs (e) 2D and (f) 3D.	77
Figure 3.8:	(a) Transmittance of TiO ₂ NRs before and after solvothermal etching. (b) UV-VIS absorbance spectrum of perovskite film deposited on TiO ₂ nanorods without TiCl ₄ treatment, TiO ₂ nanorods with TiCl ₄ treatment before and after solvothermal etching.	79

Figure 3.9:	(a) <i>I-V</i> characteristics of the junction diode made of modified TNRs. Inset of (a) shows SCLC region in all the diode. (b) Emission characteristics in three solar cell structures of TiO ₂ NRs before and after solvothermal etching. Inset of (b) shows impedance characteristics of three solar cells.	82
Figure 3.10:	(a) J_{ph} - <i>V</i> characteristics of Device A, B and C. (b) Comparison of EQE of Device A, B and C.	83
Figure 4.1:	Graphical view of the preparation process of the solutions for the seed layers (a) ZnO drop-cast (b) ZnO NPs (c) ZnO QDs (d) Solvothermal ZnO NRs.	88
Figure 4.2:	Seed layer deposition process using drop-cast, spin coating, and solvothermal. Growth of nanorods in the last step using the solvothermal process.	90
Figure 4.3:	Fabrication flow diagram for the perovskite solar cell.	92
Figure 4.4:	Top view of ZnO nanorods grown on different seed layers of (a) drop-cast (b) spin coated (ZnO NPs) (c) spin coated (ZnO QD) (d) solvothermal.	94
Figure 4.5:	XRD pattern of ZnO NR grows on different ZnO seed layers deposited using (a) drop-cast (b) spin coated (ZnO NPs) (c) spin coated (ZnO QD) (d) solvothermal.	95
Figure 4.6:	Photoluminescence emission and optical absorbance spectra of ZnO seed layer samples deposited on FTO substrate.	96
Figure 4.7:	Tau plots for different ZnO seed layer samples.	97
Figure 4.8:	Transmittance spectra of ZnO nanorods deposited on various ZnO seed layer.	100
Figure 4.9:	Impedance characteristics of PSCs A, B, C, & D	100

Figure 4.10:	Current density vs voltage (J-V) curve of four ZNRs based PSCs Fabricated on different ZnO seed layers.	101
Figure 4.11:	External quantum efficiency (EQE) of PSCs A, B, C, and D	102
Figure 5.1:	(a) Fabrication flowchart for the PSCs. (b) Complete device structure of the fabricated PSCs.	107
Figure 5.2:	(a) Energy band diagram of perovskite solar cell and (b) Equivalent electrical circuit.	109
Figure 5.3:	(a) Transmittance spectra of ZnO NRs and (b) Tauc plot for ZnO NRs.	112
Figure 5.4:	AFM image of (a) ZnO NRs without TiCl_4 treated, (b) ZnO NRs with TiCl_4 treatment, and (c) Perovskite layer on ZnO NRs	113
Figure 5.5:	HRSEM image of (a) ZnO quantum dot, (b) Solvothermally synthesized ZnO NRs, (b) Perovskite thin film on ZnO NRs, and (d) Cross-sectional image of perovskite layer on ZnO NRs.	114
Figure 5.6:	(a) Nyquist plot for fabricated PSC with undoped and doped HTL layer; (b) Equivalent circuit model employed using impedance characteristics.	116
Figure 5.7:	(a) Imaginary impedance vs. frequency plot, and (b) Real impedance vs. frequency plot of fabricated PSCs	116
Figure 5.8:	Current density vs. voltage curve for (a) Undoped spiro-OMeTAD and (b) Doped spiro-OMeTAD.	117
Figure 5.9:	External quantum efficiency of (a) Undoped spiro-OMeTAD based PSC and (b) Doped spiro-OMeTAD based PSC.	118